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Micro/Nano Photonics: Materials and Devices

**Baojun Li
Xingjun Wang
Ya Sha Yi**
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Contents

v	<i>Authors</i>
vii	<i>Symposium Committee</i>
ix	<i>Conference Committee</i>
xi	<i>Introduction</i>
xiii	<i>Conference Organizers</i>

SESSION 1

10622 02	Light emission in quantum dots and dyes doped polymer nanofibers (Invited Paper) [10622-5]
----------	--

SESSION 2

10622 03	Optical micro-cavities on silicon (Invited Paper) [10622-19]
10622 04	Towards on-chip spectroscopy based on a single microresonator (Invited Paper) [10622-59]

SESSION 3

10622 05	Temporal coupled mode theory for all-dielectric perfect absorbers [10622-18]
----------	---

SESSION 4

10622 06	MoS₂-based nanocomposites for surface enhanced Raman scattering [10622-20]
----------	--

POSTER SESSION

10622 07	Structural and optoelectronic properties of ZnGaO thin film by pulsed laser deposition [10622-3]
10622 08	Impact of the incident light polarization on photonic spin splitting around the Brewster angle [10622-10]
10622 09	Size and shape dependent optical properties of InAs quantum dots [10622-11]

- 10622 0A **Numerical modelling of high efficiency InAs/GaAs intermediate band solar cell** [10622-17]
- 10622 0B **Organic-inorganic broadband photodetector** [10622-21]
- 10622 0C **Design of control system for optical fiber drawing machine driven by double motor**
[10622-23]
- 10622 0D **Reduction of silicon waveguide endface reflection using a taper** [10622-29]
- 10622 0E **Research progress of infrared detecting and display integrated device based on infrared-visible up-conversion technology** [10622-32]
- 10622 0F **A third-order silicon racetrack add-drop filter with a moderate feature size** [10622-34]
- 10622 0G **Quantitative analysis of wide field-of-view and broadband quarter-wave plate based on metasurface** [10622-36]
- 10622 0I **Design of bent waveguide semiconductor lasers using nonlinear equivalent chirp**
[10622-42]
- 10622 0J **Design of polarization-independent transmission fused-silica grating with high diffraction efficiency** [10622-44]
- 10622 0K **SU-8 optical waveguides and devices for the 2 μ m wavelength range** [10622-45]
- 10622 0L **Terahertz broadband polarization converter based on metamaterials** [10622-56]
- 10622 0M **Photonic crystal nanofiber air-mode cavity with high Q-factor and high sensitivity for refractive index sensing** [10622-57]
- 10622 0N **Nonreciprocal optical propagation by magnetic tamm plasmon polaritons** [10622-60]

Authors

Numbers in the index correspond to the last two digits of the seven-digit citation identifier (CID) article numbering system used in Proceedings of SPIE. The first five digits reflect the volume number. Base 36 numbering is employed for the last two digits and indicates the order of articles within the volume. Numbers start with 00, 01, 02, 03, 04, 05, 06, 07, 08, 09, 0A, 0B...0Z, followed by 10-1Z, 20-2Z, etc.

Agarwal, Anu M., 04
Bo, Yu Ming, 0C
Chen, Qian, 0D, 0F
Chen, Xiangfei, 0I
Chen, Xiangning, 0D, 0F
Chen, Xin, 0M
Chen, Xinrong, 0J
Chen, Yanjun, 0G
Cheng, Chang, 02
Cheng, Yushui, 0J
Dai, Daoxin, 03, 0K
Eric, Deborah, 09, 0A
Gao, Dongwen, 07
Guo, Jingshu, 0K
Guo, Yuhao, 04
Guo, Zhe, 0G
Han, Xiaowei, 07
Han, Zhaohong, 04
He, Bo, 0E
He, Jingsuo, 0H
He, Yumeng, 0N
Hu, Zuyuan, 0J
Huang, Qingzhong, 0D, 0F
Imran, Ali, 09, 0A
Jiang, Jianliang, 09, 0A
Jiang, Wei, 0D, 0F
Jin, Xipeng, 0H
Kimerling, Lionel C., 04
Lang, Yaopu, 08
Lei, Hongxiang, 06
Li, Baojun, 02, 06, 0B
Li, Chaoming, 0J
Li, Guifang, 04
Li, Juan, 06
Li, Lianyan, 0I
Li, Shufeng, 07
Li, Weile, 0E
Li, Yanqiu, 0G
Li, Yonghua, 0L
Liu, Chao, 08
Liu, Erhu, 03
Liu, Ke, 0G
Liu, Lihui, 0G
Liu, Qinggang, 08
Ma, Xiaoxue, 0M
Michel, Jurgen, 04
Ming, Xianshun, 05
Ni, Guoqiang, 0E
Nie, Hongrui, 0M
Padilla, Willie J., 05
Pan, Yong, 07
Qin, Zirui, 08
Ren, Kun, 0N
Ren, Xiaobin, 0N
Shan, Haifeng, 0K
Shao, Yue, 0F
Shi, Yuechun, 0I
Shi, Zexia, 0H
Song, Yong, 0E
Su, Bo, 0H
Sun, Liqun, 05
Sun, Xueming, 0H
Tan, Ying, 03
Tang, Yu, 0J
Wang, Haowei, 0E
Wang, Jing, 04
Wang, Jun, 0C
Wang, Li, 07
Wang, Rui, 0J
Wang, Ruike, 0H
Wang, Ying, 0D, 0F
Wu, Jianhong, 0J
Xu, Haiyan, 0J
Xu, Junfeng, 0E
Yang, Daquan, 0M
Yang, Huaidong, 05
Yang, Shengyi, 0E
Yang, Xianguang, 02, 0B
Yousaf, Muhammad, 09, 0A
Yu, Jian, 0J
Yu, Yue Chen, 0C
Yue, Chong, 08
Zhang, Cunlin, 0H
Zhang, Lin, 04
Zhang, Shengbo, 0H
Zhang, Weina, 06
Zhang, Yunshan, 0I
Zhao, Guozhong, 0L
Zhou, Xin, 0D, 0F

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- 4 Micro/Nano Photonics
Renmin Ma, Peking University (China)
- 5 Micro/Nano Photonics
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Introduction

Micro/Nano photonics is a rising interdisciplinary field which is focused on the study of the behavior of light on the micro/nano meter scale. It is considered a branch of optical engineering which deals with optics, or the interaction of light with particles or substances, at deep subwavelength length scales. Micro/Nano photonics can provide high bandwidth, high speed and ultra-small optoelectronic components. This technology has the potential to revolutionize telecommunications, computation, sensing, optical storage, optical display, optical manipulation, solar energy utilization, and lithography, etc.

With the importance of this technology in mind, the Micro/Nano photonics, Materials and Devices Conference of OIT 2017 was organized. The conference accepted over 50 papers from different countries/areas of the world, which are focused on the design, fabrication, and application of micro/nanostructures, and crossed many research disciplines including silicon photonics integration, active nanomaterials, plasmonics, biophotonics, nonlinear optics, nanostructure device, and fabrication technology. We also invited renowned scholars to present their cutting-edge breakthroughs. These experts and contributors added to an intellectually stimulating environment.

As the Conference Chairs, we would like to express our appreciation to the committee members for their support, to the presenters for devoting their precious time to writing intriguing articles, and to the reviewers for their helpful comments. We are also grateful to the staff of SPIE for their efforts in publishing these Proceedings.

Baojun Li
Xingjun Wang
Yasha Yi

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